

## PATENT ASSIGNMENT COVER SHEET

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<b>NATURE OF CONVEYANCE:</b>	EXECUTIVE ORDER 9424, CONFIRMATORY LICENSE
<b>CONVEYING PARTY DATA</b>	
<b>Name</b>	<b>Execution Date</b>
ARIZONA STATE UNIVERSITY, TEMPE	10/11/2016
<b>RECEIVING PARTY DATA</b>	
<b>Name:</b>	National Science Foundation
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<b>PROPERTY NUMBERS Total: 1</b>	
<b>Property Type</b>	<b>Number</b>
Application Number:	15280247
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<b>Total Attachments: 1</b> source=2734#page1.tif	

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Invention Title: Damage- and resist-free laser patterning of dielectric films on textured silicon

Inventor(s): Mark Bailly

U.S. Filing/Issue Date: 09/29/2016

Patent or Application Serial No.: 15/280,247

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Foreign Applications filed/intended in (countries):

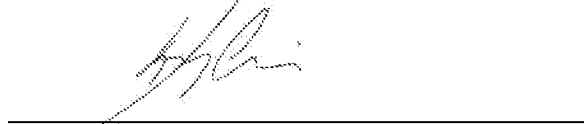
The invention identified above is a Subject Invention under **35 U.S.C. 200, et seq.**, and the Standard Patent Rights clause at **37 CFR 401.14, FAR 52.227-11 or FAR 52.227-12** (if applicable) which are included among the terms of the above identified grant or contract award from the United States Government. This document is confirmatory of:

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Signed this 11th day of October, 2016.

By Carlos Encinas



(Institutional Business Official)

(Signature)

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